

March 2018 / IN - SEM (T2)
F. Y. B.TECH. (COMMON) (SEMESTER - II)
COURSE NAME: Engineering Physics
COURSE CODE: ES 10175A
(2017 PATTERN)

Paper Code - U127-105A (T2)

Marking scheme

Q. no.	Question	Ma rks	Distribution	DL	BT	CO
Q1(a)	Define Fermi level for a semiconductor. What is Fermi-Dirac probability distribution function? Explain the terms used in it. Show that the probability of finding an electron with energy $E_F + \Delta E$ is equal to the probability of absence of an electron with energy $E_F - \Delta E$.	[6]	Definition - 1M FD - 1M Terms - 1M Derivation - 3M	M	K, C	3
Q1(b)	Draw the energy level diagram for an unbiased p-n junction diode at equilibrium. Explain the formation of built in potential on the basis of charge re-distribution in both regions. Derive the expression for built in potential (V_{bi}) for a p-n junction diode.	[6]	Diagram - 1M Explanation - 1M Derivation - 4M	M	K, C	3
Q1(c)	Find $E_F - E_{Fi}$ for an n-type semiconductor if the doping concentration is $N_D = 2.1 \times 10^{15} / \text{cm}^{-3}$. Given $n_i = 2.4 \times 10^{13} / \text{cm}^{-3}$ at 300K. Boltzmann constant $k = 8.6 \times 10^{-5} \text{ eV/K}$. How far is E_F from E_c if the band gap is 0.7 eV for Ge?	[4]	$E_F - E_{Fi} = kT \ln(N_D / n_i)$ 0.115eV $E_c - E_F = 0.115 + 0.35$ = 0.235eV	M	A	3
Q2(a)	Given density of states $g_c(E) = \frac{4}{\sqrt{\pi}} \left[\frac{m_e^*}{2\pi\hbar^2} \right]^{3/2} (E - E_c)^{1/2}$ for $E \geq E_c$, derive an expression for electron density 'n' in the conduction band.	[6]	6M	M	K, C	3
Q2(b)	Starting from the expression for current through a diode, obtain expressions for current in forward and reverse bias. Explain with help of band diagram, I-V characteristics for a diode.	[6]	Forward and reverse current- 1M each Forward and reverse explanation - 2M each	L	A, K	3
Q2(c)	Find the probability of finding an electron 0.15eV above and 0.15eV	[4]	$f = 1 / (1 + e^{(E - E_F) / kT})$ = 0.00298 1-f = 0.997	M	A	3

	below the Fermi energy at 300K, Given, $k = 8.6 \times 10^{-5} \text{ eV/K}$.					
Q3(a)	Starting from the ideal diode equation, obtain expressions for short circuit current I_{sc} and open circuit voltage V_{oc} . Give the expression for fill factor. Explain the terms in it and its significance using the I-V characteristics.	[6]	$I_{sc} - 1M$ $V_{oc} - 2M$ $FF - 1$ Significance - 2M	M	K, C	4
Q3(b)	Explain the functions of bypass diode and blocking diode while connecting solar panels in an array.	[4]	2M each	M	K, C	4
Q3(c)	A Si solar cell typically has reverse saturation current density $J_0 = 1 \times 10^{-12} \text{ A/cm}^2$. Such a Si solar cell with an area of 275 cm^2 is illuminated by sunlight of intensity $P_{\text{solar}} = 1000 \text{ W/m}^2$. Short circuit current $I_{sc} = I_L = 4.2 \text{ A}$. If the fill factor FF of the cell is 0.65, then calculate efficiency of the solar cell at 27°C .	[4]	$V_{oc} = \frac{kT}{q} \ln \left(\frac{I_L}{I_0} \right)$ $= 0.0258$ $\times \ln \left(\frac{4.2}{2.75 \times 10^{-10}} \right)$ $= 0.605 \text{ V}$ $\eta = \frac{I_{sc} V_{oc} FF}{P_{in}}$ $= \frac{3.3 \times 0.605 \times 0.65}{27.5}$ $= 0.0472$	H	A	4
Q4(a)	Define and explain the following battery parameters: (i) battery capacity (ii) depth of discharge (iii) C-rating.	[6]	2M each	M	C, A	4
Q4(b)	Explain use of anti-reflection coating and surface texturing to enhance efficiency of a solar cell.	[4]	2M each	M	C, A	4
Q4(c)	Four solar cells are connected in series in a row. Seven such rows are connected in parallel to form an array. Calculate open circuit voltage $(V_{oc})_{\text{array}}$ and short circuit current $(I_{sc})_{\text{array}}$ for the array. Given, $V_{oc} = 0.6 \text{ V}$ and $I_{sc} = 1 \text{ A}$ for a single solar cell.	[4]	$(V_{oc})_{\text{array}} = 4 \times 0.6 = 2.4 \text{ V}$ $(I_{sc})_{\text{array}} = 7 \times 1 = 7 \text{ A}$	L	A	4